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MSE-351 Surface analysis Mischler Stefano, Stolichnov Igor Cursus Sem. Туре Language of English Materials Science and Engineering MA1, MA3 Opt. teaching Credits 3 Withdrawal Unauthorized Winter Session Semester Fall During the Exam semester Workload 90h Weeks 14 Hours 3 weekly 2 weekly Courses TΡ 1 weekly Number of 18 positions It is not allowed to withdraw from this subject after the registration deadline.

Summary

The course treats the main surface analysis methods for the characterization of surfaces, interfaces and thin films. It discusses how these methods can be applied to gain specific knowledge about structural, chemical and functional properties of surfaces and thin films. Limitation to 18 students!

Content

- 1. Introduction
- 2. Introduction to electronic states on atoms
- 3. Photo Electron Spectroscopy and Chemical Analysis (ESCA/XPS)
- 4. Auger Electron Spectroscopy (AES)
- 5. Secondary Ion Mass Spectrometry (SIMS)
- 6. Depth profiling
- 7. Electron diffraction from surfaces
- 8. Scanning Tunnelling Microscopy (STM)
- 9. Atomic Force Microscopy (AFM)
- 10. Quantitative measurements of surface properties with AFM

Keywords

electronic states on atoms, angular momentum, spin, particle wavelength, photoélectrons, energy analyzers, chemical composition, interatomic forces like van der Waal's, surface topography, image of magnetic and piezoelectric responses

Learning Outcomes

By the end of the course, the student must be able to:

- Describe the main features of surface analysis
- Differentiate advantages and disadvantages
- Choose the appropriate methodes

Transversal skills

- Use a work methodology appropriate to the task.
- Access and evaluate appropriate sources of information.

• Evaluate one's own performance in the team, receive and respond appropriately to feedback.

Teaching methods

ex-cathedra and exercises / TP: experimental work with assistants on XPS or AFM in groups of about 4 / presentation on results and interpretation

Expected student activities

learn, look up, make exercises

Assessment methods

written exam

Resources

Bibliography

Leonard C. Feldmann and James W. Mayer, Fundamentals of surface and thin film analysis , North-Holland, (Elsevier) 1986 Hans Jörg Mathieu, Erich Bergmann, and René Gras, Analyse et technologie des surfaces , Presses polytechniques et universitaires romandes, 2003. D.J. O¿Connor, B.A. Sexton, R.St.C. Smart (eds), Surface analysis methods in materials science , Springer, 2003.

Ressources en bibliothèque

- Analyse et technologies des surfaces / Mathieu
- Surface analysis methods in materials science / Connor
- Fundamentals of surface and thin film analysis / Feldman

Notes/Handbook

copies of foils, script available as pdf file

Moodle Link

• http://moodle.epfl.ch